

ELECTRONIC INFORMATION DISCLOSURE STATEMENT

Electronic Version v18

Stylesheet Version v18.0

Title of Invention

TWO-MASK PROCESS FOR METAL-INSULATOR-METAL
CAPACITORS AND SINGLE MASK PROCESS FOR THIN FILM
RESISTORS

Application Number :

10/605,260

Confirmation Number:

First Named Applicant:

Glenn A. Biery

Attorney Docket Number:

FIS920030147US1

Art Unit:

Examiner:

Search string:

(6278147 or 6278147 or 6278147 or 6278147 or 6278147 or 6278147 or 6278147
or 6278147).pn

US Patent Documents

Note: Applicant is not required to submit a paper copy of cited US Patent Documents

init	Cite.No.	Patent No.	Date	Patentee	Kind	Class	Subclass
1A	1	6278147	2001-08- 21	Dalton, et al.	—	—	—
	2	6387754	2002-05- 14	Dalton, et al.	—	—	—
	3	6413815	2002-07- 02	Lai, et al.	—	—	—
	4	6451667	2002-09- 17	Ning	—	—	—
	5	6461914	2002-10- 08	Roberts, et al.	—	—	—
	6	6468858	2002-10- 22	Lou	—	—	—
	7	6528366	2003-03- 04	Tu, et al.	—	—	—
1A	8	6580111	2003-06- 17	Kim, et al.	—	—	—

Signature

Examiner Name

Agarwal

Date

3/1/04